

Amendments to the Specification

Please amend the text at page 10, lines 5 to 7, as shown below:

~~6~~ The use of external heating yields the allowance of
~~enables the independent control of the temperature of~~
~~glass substrate 320 temperature and magnetic flux~~
~~density on silicon film films 220, which is not the~~
~~case in the embodiments of FIGS 1 and 2.~~
